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Surface chemical analysis — Analysis of zinc- and/or aluminium-based metallic coatings by glow-discharge optical-emission spectrometry

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National foreword

This British Standard is the UK implementation of ISO 16962:2017.

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A list of organizations represented on this committee can be obtained on request to its secretary.

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INTERNATIONAL STANDARD

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Surface chemical analysis — Analysis of zinc- and/or aluminium-based metallic coatings by glow-discharge optical-emission spectrometry

Analyse chimique des surfaces — Analyse des revêtements métalliques à base de zinc et/ou d'aluminium par spectrométrie d'émission optique à décharge luminescente

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Contents

Page

Foreword ..... **v**
Introduction ..... **vi**
1 Scope **1**
2 Normative references **1**
3 Terms and definitions **1**
4 Principle **1**
5 Apparatus **2**
5.1 Glow-discharge optical-emission spectrometer 2
5.1.1 General 2
5.1.2 Selection of spectral lines 2
5.1.3 Selection of glow-discharge source type 2
6 Adjusting the glow-discharge spectrometer system settings **3**
6.1 General 3
6.2 Setting the parameters of a DC source 4
6.2.1 Constant applied current and voltage 4
6.2.2 Constant applied current and pressure 5
6.2.3 Constant voltage and pressure 5
6.3 Setting the discharge parameters of an RF source 6
6.3.1 General 6
6.3.2 Constant applied power and pressure 6
6.3.3 Constant applied power and DC bias voltage 6
6.3.4 Constant effective power and effective RF voltage 7
6.4 Minimum performance requirements 7
6.4.1 General 7
6.4.2 Minimum repeatability 7
6.4.3 Detection limit 8
7 Sampling **9**
8 Calibration **9**
8.1 General 9
8.2 Calibration samples 10
8.2.1 General 10
8.2.2 Brass calibration samples 10
8.2.3 Zn-Al alloy samples 10
8.2.4 Low alloy iron or steel samples 10
8.2.5 Stainless steel samples 10
8.2.6 Nickel alloy samples 10
8.2.7 Aluminium-silicon alloy samples 10
8.2.8 Aluminium-magnesium alloy samples 10
8.2.9 High-purity copper and zinc samples 11
8.3 Validation samples and optional RMs for calibration 11
8.3.1 General 11
8.3.2 Zinc-nickel electrolytically coated RM 11
8.3.3 Zinc-iron electrolytically coated RM 11
8.3.4 Zinc-aluminium hot dip coated RM 11
8.3.5 Zinc-iron hot dip coated and annealed RM 11
8.4 Determination of the sputtering rate of calibration and validation specimens 11
8.5 Emission intensity measurements of calibration specimens 13
8.6 Calculation of calibration equations 13
8.7 Validation using reference materials 13
8.7.1 General 13
8.7.2 Checking analytical accuracy using bulk reference materials 13

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Full document details: BS ISO 16962:2017

8.7.3 Checking analytical accuracy using surface layer reference materials ... 14
8.8 Verification and drift correction ... 14

9 Analysis of test specimens ... 15
9.1 Adjusting discharge parameters ... 15
9.2 Setting of measuring time and data acquisition rate ... 15
9.3 Quantifying depth profiles of test specimens ... 15

10 Expression of results ... 15
10.1 Expression of quantitative depth profile ... 15
10.2 Determination of total coating mass per unit area (coating aeric mass) ... 17
10.2.1 General method ... 17
10.2.2 Method for special applications ... 17
10.3 Determination of average mass fractions ... 17

11 Precision ... 17

12 Test report ... 18

Annex A (normative) **Calculation of calibration constants and quantitative evaluation of depth profiles ... 19**

Annex B (informative) **Suggestions concerning suitable spectral lines ... 31**

Annex C (informative) **Determination of coating mass per unit area (coating areic mass) ... 32**

Annex D (informative) **Additional information on international cooperative tests ... 38**

Bibliography ... 40

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Full document details: BS ISO 16962:2017

Foreword

ISO (the International Organization for Standardization) is a worldwide federation of national standards bodies (ISO member bodies). The work of preparing International Standards is normally carried out through ISO technical committees. Each member body interested in a subject for which a technical committee has been established has the right to be represented on that committee. International organizations, governmental and non-governmental, in liaison with ISO, also take part in the work. ISO collaborates closely with the International Electrotechnical Commission (IEC) on all matters of electrotechnical standardization.

The procedures used to develop this document and those intended for its further maintenance are described in the ISO/IEC Directives, Part 1. In particular the different approval criteria needed for the different types of ISO documents should be noted. This document was drafted in accordance with the editorial rules of the ISO/IEC Directives, Part 2 (see www.iso.org/directives).

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For an explanation on the voluntary nature of standards, the meaning of ISO specific terms and expressions related to conformity assessment, as well as information about ISO's adherence to the World Trade Organization (WTO) principles in the Technical Barriers to Trade (TBT) see the following URL: www.iso.org/iso/foreword.html.

This document was prepared by Technical Committee ISO/TC 201, *Surface chemical analysis*, Subcommittee SC 8, *Glow discharge spectroscopy*.

This second edition cancels and replaces the first edition (ISO 16962:2005), which has been technically revised.

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Introduction

This document is a revision of ISO 16962. Developments in both GD-OES instrumentation and the types of zinc- and/or aluminium-based metallic coatings currently produced have rendered ISO 16962 partly obsolete, and this revision is intended to bring it up to date.

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INTERNATIONAL STANDARD ISO 16962:2017(E)

Surface chemical analysis — Analysis of zinc- and/or aluminium-based metallic coatings by glow-discharge optical-emission spectrometry

1 Scope

This document specifies a glow-discharge optical-emission spectrometric method for the determination of the thickness, mass per unit area and chemical composition of metallic surface coatings consisting of zinc- and/or aluminium-based materials. The alloying elements considered are nickel, iron, silicon, lead and antimony.

This method is applicable to zinc contents between 0,01 mass % and 100 mass %; aluminium contents between 0,01 mass % and 100 mass %; nickel contents between 0,01 mass % and 20 mass %; iron contents between 0,01 mass % and 20 mass %; silicon contents between 0,01 mass % and 15 mass %; magnesium contents between 0,01 mass% and 20 mass%; lead contents between 0,005 mass % and 2 mass %, antimony contents between 0,005 mass % and 2 mass %.

NOTE Due to environmental and health risks, lead and antimony are avoided nowadays, but this document is also applicable to older products including these elements.

2 Normative references

The following documents are referred to in the text in such a way that some or all of their content constitutes requirements of this document. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

ISO 14284, *Steel and iron — Sampling and preparation of samples for the determination of chemical composition*

ISO 17925, *Zinc and/or aluminium based coatings on steel — Determination of coating mass per unit area and chemical composition — Gravimetry, inductively coupled plasma atomic emission spectrometry and flame atomic absorption spectrometry*

3 Terms and definitions

No terms and definitions are listed in this document.

ISO and IEC maintain terminological databases for use in standardization at the following addresses:

— IEC Electropedia: available at http://www.electropedia.org/

— ISO Online browsing platform: available at http://www.iso.org/obp

4 Principle

The analytical method described here involves the following processes:

a) preparation of the sample to be analysed, generally in the form of a flat plate or disc of dimensions appropriate to the instrument or analytical requirement (round or rectangular samples with a width of more than 5 mm, generally 20 mm to 100 mm, are suitable);

b) cathodic sputtering of the surface coating in a direct current or radio frequency glow-discharge device;

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c) excitation of the analyte atoms in the plasma formed in the glow-discharge device;

d) spectrometric measurement of the intensities of characteristic emission spectral lines of the analyte atoms and ions as a function of sputtering time (qualitative depth profile);

e) conversion of the depth profile in units of intensity versus time to mass fraction versus depth by means of calibration functions (quantification). Calibration of the system is achieved by measurements on calibration samples of known chemical composition and measured sputtering rate.

5 Apparatus

5.1 Glow-discharge optical-emission spectrometer

5.1.1 General

The required instrumentation includes an optical-emission spectrometer system consisting of a Grimm type[1] or similar glow-discharge source (direct current or radio frequency powered) and a simultaneous optical spectrometer as described in ISO 14707, capable of providing suitable spectral lines for the analyte elements. It is also common to combine this with a sequential spectrometer (monochromator), allowing the addition of an extra spectral channel to a depth profile measurement. An array-type detector, such as a charge coupled device (CCD) or a charge injection device (CID) can also be used for simultaneous detection to cover a wide spectral range of the analytical lines.

The inner diameter of the hollow anode of the glow-discharge source should be in the range 2 mm to 8 mm. A cooling device for thin specimens, such as a metal block with circulating cooling liquid, is also recommended, but not strictly necessary for implementation of the method.

Since the principle of determination is based on continuous sputtering of the surface layer, the spectrometer shall be equipped with a digital readout system for time-resolved measurement of the emission intensities. A system capable of a data acquisition speed of at least 300 measurements/second per spectral channel is recommended, but for a large number of applications speeds of > 50 measurements/second per spectral channel are acceptable. In practice, it has been established that 10 to 100 measurements/second per spectral channel are suitable.

5.1.2 Selection of spectral lines

For each analyte to be determined, there exist a number of spectral lines which can be used. Suitable lines shall be selected on the basis of several factors, including the spectral range of the spectrometer used, the analyte mass fraction range, the sensitivity of the spectral lines and any spectral interference from other elements present in the test specimens. For applications where several of the analytes of interest are major elements in the specimens, special attention shall be paid to the occurrence of self-absorption of certain highly sensitive spectral lines (so-called “resonance lines”). Self-absorption causes non-linear calibration curves at high analyte mass fraction levels, and strongly self-absorbed lines should therefore be avoided for the determination of major elements. Suggestions concerning suitable spectral lines are given in Annex B. Spectral lines other than those listed may be used, so long as they have favourable characteristics.

5.1.3 Selection of glow-discharge source type

5.1.3.1 Anode size

Most GD-OES instruments on the market are delivered with options to use various anode diameters, 2 mm, 4 mm and 8 mm being the most common. Some older instruments have one anode only, usually 8 mm, while the most commonly used anode in modern instruments is 4 mm. A larger anode requires larger specimens and higher power during analysis; therefore, the specimen is heated to a greater extent. On the other hand, a larger anode gives rise to a plasma of larger volume that emits more light, resulting in lower detection limits (i.e. higher analytical sensitivity). Furthermore, a larger anode helps

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to mask inhomogeneity within a surface layer. This may or may not be an advantage, depending on the application. In a large number of applications, the 4 mm anode is a good compromise. However, in surface analysis applications, it is rather common to encounter problems of overheating of the specimens due to surface layers of poor heat conductivity and/or very thin specimens, for example. In such cases, a smaller anode (typically 2 or 2,5 mm) is preferable, even if there is some loss of analytical sensitivity.

5.1.3.2 Type of power supply

The glow-discharge source can be either a type powered by a direct current (DC) power supply or a radio frequency (RF) type. The most important difference is that the RF type can sputter both conductive and non-conductive specimens; hence, this is the only type that can be used for polymer coatings and insulating oxide layers, for example. On the other hand, it is technically simpler to measure and control the electrical source parameters (voltage, current, power) of a DC type. Several commercially available GD-OES systems can be delivered with the option to switch between DC and RF operation, but RF-only systems are becoming increasingly common. In short, there are a very large number of applications where DC or RF sources can be used and several where only an RF source can be used.

5.1.3.3 Mode of operation

Both DC and RF sources can be operated in several different modes with respect to the control of the electrical parameters (current, voltage, power) and the pressure. There are several reasons for this:

— "historical" reasons (older instruments have simpler but functional power supplies, while the technology has evolved, so newer models have more precise and easier-to-operate source control);

— different manufacturers have chosen different solutions for source control;

— there are some application-related issues where a particular mode of operation is to be preferred.

This document gives instructions for optimizing the source parameters based on several available modes of operation. The most important reason for this is to make these instructions comprehensive so as to include several types of instruments. In most applications, there is no major difference between these modes in terms of analytical performance, but there are other differences in terms of practicality and ease of operation. For instance, a system equipped with active pressure regulation will automatically be adjusted to the same electrical source parameters every time a particular analytical method is used. Without this technology, some manual adjustment of the pressure to achieve the desired electrical source parameters is normally required.

NOTE In this context, what is known as the emission yield[2][3][4][7] forms the basis for calibration and quantification as described in this document. The emission yield has been found to vary with the current, the voltage and, to a lesser extent, the pressure[4][7]. It is impossible in practice to maintain all three parameters constant for all test specimens, due to variations in the electrical characteristics of different materials. In several instrument types, the electrical source parameters (the plasma impedance) can therefore be maintained constant by means of automatic systems that vary the pressure during analysis. Alternatively, there exist methods to correct for impedance variations by means of empirically derived functions[4][7], and this type of correction is implemented in the software of commercially available GD-OES systems.

6 Adjusting the glow-discharge spectrometer system settings

6.1 General

Follow the manufacturer's instructions or locally documented procedures for preparing the instrument for use.

For the optical system, the most important preparation step is to check that the entrance slit to the spectrometer is correctly adjusted, following the procedure given by the instrument manufacturer. This ensures that the emission intensities are measured on the peaks of the spectral lines for optimum signal-to-background ratio and good reproducibility. For further information, see ISO 14707.

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The most important step in developing a method for a particular application is to optimize the parameters of the glow-discharge source. The source parameters shall be chosen to achieve three aims:

a) adequate sputtering of the test specimen, to reduce the analysis time without overheating the specimen;

b) good crater shape, for good depth resolution;

c) constant excitation conditions in calibration and analysis, for optimum accuracy.

Trade-offs are often necessary among the three specified aims. More detailed instructions on how to adjust the source parameters are given in 6.2 and 6.3.

The settings of the high voltage for the detectors depend on the source parameters, but the procedure is the same for all modes of operation of the source. This procedure is therefore only described for the first mode of operation.

Similarly, the steps to adjust and optimize the source settings in terms of signal stability and sputter crater shape are also similar in principle for all modes of operation. Therefore, these procedures are only described in detail for the first mode of operation.

NOTE There is no difference between DC and RF concerning the possibilities to measure the pressure. However, there are large pressures differentials in a Grimm type source, and pressure readings obtained depend on the location of the pressure gauge. Some instrument models have a pressure gauge attached to measure the actual pressure in the plasma, while others have a pressure gauge located on a “low pressure” side of the source closer to the pump. Therefore, the pressure readings can, for several instruments, just be used to adjust the source parameters of that particular instrument, not as a measure of the actual operating pressure in the plasma.

6.2 Setting the parameters of a DC source

6.2.1 Constant applied current and voltage

6.2.1.1 General

The two control parameters are the applied current and the applied voltage. Set the power supply for the glow-discharge source to constant current/constant voltage operation (current set by the power supply, voltage adjusted by pressure/gas flow regulation). Then, set the current and voltage to the typical values recommended by the manufacturer. Alternatively, set the power supply to constant voltage/constant current operation (voltage set by the power supply, current adjusted by pressure/gas flow regulation). If no recommended values are available, set the voltage to 700 V and the current to a value in the range 5 mA to 10 mA for a 2 mm or 2,5 mm anode, 15 mA to 30 mA for a 4 mm anode or 40 mA to 100 mA for a 7 mm or 8 mm anode. If no previous knowledge of the optimum current is available, it is recommended to start with a value somewhere in the middle of the recommended range.

NOTE For the purposes of this document, there is no difference between the two alternative modes of operation described above. However, for applications to very thin films, there may be a small difference in the very short start-up of the discharge, affecting the analytical results to some extent.

6.2.1.2 Setting the high voltage of the detectors

Select test specimens with surface layers of all types to be determined. For all test specimens, run the source while observing the output signals from the detectors for the analyte atoms. Adjust the high voltage of the photomultiplier (PMT) detectors in such a way that sufficient sensitivity is ensured at the lowest analyte mass fraction without saturation of the detector system at the highest analyte mass fraction. For array type detectors (CCD or CID), adjust the integration time in the same way as the high voltage for PMT.

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6.2.1.3 Adjusting the source parameters

For each type of test specimen, carry out a full-depth profile measurement, sputtering it in the glow discharge for a sufficiently long time to remove the surface layers completely and continue well into the base material. By observing the emission intensities as a function of sputtering time (often referred to as the "qualitative depth profile"), verify that the selected source settings give stable emission signals throughout the depth profile and into the substrate. If this is found not to be the case, reduce one of the control parameters by a small amount and sputter through the surface layers again. If the stability is still unsatisfactory, reduce the other control parameter by a small amount and repeat the measurements. If found necessary, repeat this procedure for a number of control parameter combinations until stable emission conditions are obtained.

NOTE Unstable emission signals could indicate thermal instability in the specimen surface layers; specimen cooling is beneficial in this regard.

6.2.1.4 Optimizing the crater shape

If a suitable profilometer device is available, adopt the following procedure. Sputter a specimen with a surface layer typical of the test specimens to be analysed to a depth of about 10 µm to 20 µm, but still inside the surface layer. This is only possible for application where surface layers of such thickness are available. If no such specimen is available, use a steel or brass specimen. Measure the crater shape by means of the profilometer device. Repeat this procedure a few times using slightly different values of one of the control parameters. Select the conditions that give an optimally flat-bottomed crater. These conditions are then used during calibration and analysis, provided that the stability of the emission conditions obtained in step 6.2.1.3 is not compromised. In some cases, there is a certain trade-off between these two requirements.

6.2.2 Constant applied current and pressure

The two control parameters are the applied current and the pressure. Set the power supply for the glow-discharge source to constant current operation. Then, set the current to a typical value recommended by the manufacturer. If no recommended values are available, set the current to a value in the range 5 mA to 10 mA for a 2 mm or 2,5 mm anode, 15 mA to 30 mA for a 4 mm anode or 40 mA to 100 mA for a 7 mm or 8 mm anode. If no previous knowledge of the optimum current is available, it is recommended to start with a value somewhere in the middle of the recommended range. Sputter a typical coated test specimen, and adjust the pressure until a voltage of approximately 700 V is attained in the surface layer.

Set the high voltage of the detectors as described in 6.2.1.2.

Adjust the source parameters as described in 6.2.1.3, adjusting first the current and, if necessary, the pressure.

Optimize the crater shape as described in 6.2.1.4 by adjusting the pressure. These conditions are then used during calibration and analysis.

NOTE Before sputtering a new specimen type, make a test run in order to ensure that the voltage has not changed by more than 5 % from the previously selected value. If this is the case, readjust the pressure until the correct value is attained.

6.2.3 Constant voltage and pressure

The two control parameters are applied voltage and pressure. Set the power supply for the glow-discharge source to constant voltage operation. First, set the voltage to a typical value recommended by the manufacturer. If no recommended values are available, set the voltage to 700 V. Sputter a typical coated test sample, and adjust the pressure until a current is attained in the range 5 mA to 10 mA for a 2 mm or 2,5 mm anode, 15 mA to 30 mA for a 4 mm anode, 40 mA to 100 mA for a 7 mm or 8 mm anode in the surface layers. If no previous knowledge about the optimum current is available, it is recommended to start with a value somewhere in the middle of the recommended range.

Set the high voltage of the detectors as described in 6.2.1.2.

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Adjust the source parameters as described in 6.2.1.3, adjusting first the voltage and, if necessary, the pressure.

Optimize the crater shape as described in 6.2.1.4, by adjusting the pressure. These conditions are then used during calibration and analysis.

NOTE Before sputtering a new sample type, make a test run in order to ensure that the current is not altered more than 5 % from the previously selected value. If this is the case, readjust the pressure until the correct value is attained.

6.3 Setting the discharge parameters of an RF source

6.3.1 General

The most common operating modes of RF sources are the following: constant applied power and constant pressure; constant applied voltage and constant pressure; or constant effective power and applied voltage. All RF operational modes are allowed in this document, provided they meet the three aims listed in 6.1. In the following, separate instructions are provided on how to set the parameters for the different operational modes.

NOTE RF sources differ from DC sources in the respect that for several instrument models, only the applied (forward) RF power can be measured, not the actual power developed in the glow-discharge plasma. The applied RF power is normally in the range 10 W to 100 W, but it must be noted that the RF power losses in connectors, cables, etc. vary considerably between different instrument models and the point of contact of the RF power to the sample. Typical power losses are in the range 10 % to 50 % of the applied power. Furthermore, the possibilities to measure the additional electrical parameters voltage and current in the plasma are more or less restricted due to technical difficulties with RF systems, and several existing instrument models can only measure the applied RF power.

6.3.2 Constant applied power and pressure

The two control parameters are the applied power and the pressure. First, set the applied power and adjust the source pressure to the values suggested by the manufacturer. If recommended values are not available, set the applied power and pressure to somewhere in the middle of the ranges available for the instrument used. Measure the penetration rate (i.e. depth per unit time) on an iron or steel specimen, adjusting the power to give a penetration rate of about 2 µm/min to 3 µm/min.

Set the high voltage of the detectors as described in 6.2.1.2.

Adjust the source parameters as described in 6.2.1.3, adjusting first the applied power and, if necessary, the pressure.

Optimize the crater shape as described in 6.2.1.4 by adjusting the pressure.

Remeasure the penetration rate on the iron or steel specimen and adjust the applied power, if necessary, to return to about 2 µm/min to 3 µm/min. Repeat the cycle of power and pressure adjustment until no significant change is noted in the penetration rate or crater shape. Note the power and pressure used in units provided for the instrument type. These conditions are then used during calibration and analysis.

6.3.3 Constant applied power and DC bias voltage

The two control parameters are the applied power and the DC bias voltage. First, set the applied power and adjust the source pressure to attain a DC bias typical of the values suggested by the manufacturer. If recommended values are not available, set the applied power and DC bias voltage to somewhere in the middle of the range commonly used for depth profiling of metal specimens. On instruments equipped with active pressure control, this can be achieved automatically. Measure the penetration rate (i.e. depth per unit time) on an iron or steel specimen, adjusting the power to give a penetration rate of about 2 µm/min to 3 µm/min.

Set the high voltage of the detectors as described in 6.2.1.2.

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Adjust the discharge parameters as described in 6.2.1.3, adjusting first the applied power and, if necessary, the DC bias voltage.

Optimize the crater shape as described in 6.2.1.4 by adjusting the DC bias voltage.

Remeasure the penetration rate on the iron or steel specimen and adjust the applied power, if necessary, to return to about 2 µm/min to 3 µm/min. Repeat the cycle of power and DC bias voltage adjustment until no significant change is noted in the penetration rate or in the crater shape. If this is not the case, readjust the DC bias voltage until the correct value is attained. Note the power and DC bias voltage used in units provided for the instrument. These conditions are then used during calibration and analysis.

6.3.4 Constant effective power and effective RF voltage

The two control parameters are the effective power and the RF voltage. Constant effective power is defined here as the applied power minus the reflected power and the "blind power" measured with the specimen in place but without plasma (vacuum conditions). The RF voltage is defined here as the RMS voltage at the coupling electrode without DC bias[8][9].

Set the power supply for the glow-discharge source to constant effective power/constant RF voltage operation. First, set the power to a typical value recommended by the manufacturer. If no recommended values are available, set the RF voltage to 700 V and the power to a value in the range 10 W to 15 W for a 4 mm anode, 5 to 10 W for a 2 mm anode to give an example. If no previous knowledge of the optimum power is available, it is recommended to start with a value somewhere in the middle of the recommended range.

Set the high voltage of the detectors as described in 6.2.1.2.

Adjust the discharge parameters as described in 6.2.1.3, adjusting first the effective power and, if necessary, the RF voltage.

Optimize the crater shape as described in 6.2.1.4 by adjusting the RF voltage. Select the conditions that give an optimally flat-bottomed crater. These conditions are then used during calibration and analysis.

6.4 Minimum performance requirements

6.4.1 General

It is desirable for the instrument to conform to the performance specifications given in 6.3.2 and 6.3.3 below.

NOTE Setting up for analysis commonly requires an iterative approach to the adjustment of the various instrumental parameters described in this document.

6.4.2 Minimum repeatability

The following test shall be performed in order to check that the instrument is functioning properly in terms of repeatability.

Perform 10 measurements of the emission intensity on a homogeneous bulk specimen with a content of the analyte exceeding a mass fraction of 1 %. The glow-discharge conditions shall be those selected for analysis. These measurements shall be performed using a discharge stabilization time (often referred to as "preburn") of at least 60 s and a data acquisition time in the range 5 s to 20 s. Each measurement shall be located on a newly prepared surface of the specimen. Calculate the relative standard deviation of the 10 measurements. The relative standard deviation shall conform to any requirements and/or specifications relevant to the intended use.

NOTE Typical relative standard deviations determined in this way are 2 % or less.

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6.4.3 Detection limit

6.4.3.1 General

Detection limits are instrument-dependent and matrix-dependent. Consequently, the detection limit for a given analyte cannot be uniquely determined for every available instrument or for the full range of surface layers considered here. For the purposes of this document, the detection limit for each analyte will be acceptable if it is equal to or less than one-fifth of the lowest expected mass fraction in the surface layer to be analysed.

6.4.3.2 SNR method

The first method is often called the "signal-to-noise ratio (SNR) method". In order to evaluate the detection limit for a given analyte, the following steps are performed.

Select a bulk specimen to be used as a blank. The composition of the specimen should preferably be similar, in terms of the elemental composition of the matrix, to that of the surface layers to be analysed. Further, the specimen shall be known to contain less than 1 µg/g of the analyte.

Perform 10 replicate burns on the blank. For each burn, acquire the emission intensity at the analytical wavelength for 10 s. These are the background emission intensity measurements. The glow-discharge conditions used should preferably be the same as those that will be used in the analysis of the coated specimens. For each measurement, the blank shall be preburned at these conditions for a sufficient length of time to achieve stable signals prior to the quantification of the emission intensity. Use an unsputtered area of the surface of the blank for each individual burn.

Compute the detection limit, expressed as a mass fraction, using Formula (1):

$$\mathrm{DL} = \frac{3 \times \sigma}{S} \tag{1}$$

where

DL is the detection limit;

σ is the standard deviation of the background intensity measurements performed in step 2;

S is the analytical sensitivity derived from the instrument calibration, expressed in the appropriate units (the ratio of intensity to mass fraction).

If the detection limit calculated is unacceptable, the test shall be repeated. If the second value calculated is also unacceptable, then the cause shall be investigated and corrected prior to analysing specimens.

6.4.3.3 SBR-RSDB method

The second method, which does not require a blank, is often called the "signal-to-background ratio — relative standard deviation of the background (SBR-RSDB) method". The method is performed as follows.

a) Select a bulk specimen which has a matrix composition that is similar to that of the surface layers to be analysed and in which the mass fraction of the analyte is greater than 0,1 % and accurately known. If an analytical transition that is prone to self-absorption (see 5.1.2) is to be used, the mass fraction of the analyte should preferably not exceed 1 %.

b) Perform three replicate burns on the chosen specimen. For each burn, integrate the emission intensity at the analytical wavelength for 10 s. The glow-discharge conditions used shall be similar to those that will be used in the analysis of the coated specimens. For each measurement, the specimen shall be preburned at these conditions for a sufficient length of time to achieve stable

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